## IN THE CLAIMS:

- 1. A staggered torsional electrostatic combdrive, comprising:
  - a stationary combteeth assembly; and
- 5 a moving combteeth assembly including a mirror and a torsional hinge, said moving combteeth assembly being positioned entirely above said stationary combteeth assembly by a predetermined vertical displacement during a combdrive resting state.
- The staggered torsional electrostatic combdrive of claim 1 wherein said mirror
   is formed of single-crystal silicon.
  - 3. The staggered torsional electrostatic combdrive of claim 2 wherein individual moving combteeth of said moving combteeth assembly are positioned between individual stationary combteeth of said stationary combteeth assembly during a combdrive activation state, and said mirror intersects the plane defined by said stationary combteeth during said combdrive activation state.
  - The staggered torsional electrostatic combdrive of claim 3 wherein said mirror pivots about said torsional hinge during said combdrive activation state.
  - The staggered torsional electrostatic combdrive of claim 1 wherein said predetermined vertical displacement is between 0.2 and 3.0 microns.
  - The staggered torsional electrostatic combdrive of claim 1 wherein said moving combteeth assembly further includes an anchor, said torsional hinge being positioned between said mirror and said anchor.
    - The staggered torsional electrostatic combdrive of claim 1 wherein said moving combteeth assembly has a thickness of between 10 and 500 microns.
    - The staggered torsional electrostatic combdrive of claim 7 wherein said moving combteeth assembly has a thickness of between 50 and 100 microns.

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- The staggered torsional electrostatic combdrive of claim 1 wherein said mirror has a lateral length of less than 10 millimeters.
- The staggered torsional electrostatic combdrive of claim 1 wherein said mirror has a lateral length of between 550 and 2000 microns.
  - 11. The staggered torsional electrostatic combdrive of claim 1 said moving combteeth assembly has a comb tooth gap of between 2-30 microns between individual combteeth of said moving combteeth assembly.

12. The staggered torsional electrostatic combdrive of claim 1 wherein the position of said moving combteeth assembly is adjusted in response to a capacitance value measured between said moving combteeth assembly and said stationary combteeth assembly.

13. The staggered torsional electrostatic combdrive of claim 1 further comprising a stacked combteeth assembly positioned over said stationary combteeth assembly.

- 14. The staggered torsional electrostatic combdrive of claim 13 wherein the position of said moving combteeth assembly is adjusted in response to a capacitance value measured between said moving combteeth assembly and said stacked combteeth assembly.
- 15. The staggered torsional electrostatic combdrive of claim 13 wherein said 25 stacked combteeth assembly is operated to alter the resonant frequency of said moving combteeth assembly.
  - 16. The staggered torsional electrostatic combdrive of claim 1 wherein said moving combteeth assembly includes a combteeth spine with a first set of individual combteeth extending in a first direction from said spine and a second set of individual combteeth extending in a second direction from said spine.

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- 17. The staggered torsional electrostatic combdrive of claim 16 further comprising an additional stationary combteeth assembly positioned to selectively engage said second set of individual combteeth; wherein said first set of individual combteeth selectively engages said stationary combteeth assembly.
- 18. The staggered torsional electrostatic combdrive of claim 17 wherein the position of said moving combteeth assembly is adjusted in response to a capacitance value measured between said moving combteeth assembly and said additional stationary combteeth assembly.

 The staggered torsional electrostatic combdrive of claim 17 further comprising a stacked combteeth assembly positioned over said additional stationary combteeth assembly.

- 15 20. The staggered torsional electrostatic combdrive of claim 19 wherein the position of said moving combteeth assembly is adjusted in response to a capacitance value measured between said moving combteeth assembly and said stacked combteeth assembly.
- 20 21. The staggered torsional electrostatic combdrive of claim 1 further comprising transparent substrates enclosing said stationary comb teeth assembly and said moving comb teeth assembly.
- The staggered torsional electrostatic combdrive of claim 1 wherein said mirror
   includes a reflective material
  - The staggered torsional electrostatic combdrive of claim 1 wherein said mirror includes a multilayer optical filter.
- 30 24. A staggered torsional electrostatic combdrive, comprising: a stationary combteeth assembly; and

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a moving combteeth assembly including a paddle and a torsional hinge, said moving combteeth assembly being positioned entirely above said stationary combteeth assembly by a predetermined vertical displacement during a combdrive resting state.

- 5 25. The staggered torsional electrostatic combdrive of claim 24 wherein said paddle supports a mounted electronic component.
  - 26. The staggered torsional electrostatic combdrive of claim 25 wherein said mounted electronic component is an ultrasonic transducer.
  - 27. The staggered torsional electrostatic combdrive of claim 25 wherein said mounted electronic component is an ultrasonic sensor.
- A method of fabricating a staggered torsional electrostatic combdrive, said
   method comprising the steps of:

deep trench etching a stationary combteeth assembly in a first wafer; bonding a second wafer to said first wafer to form a sandwich including said first wafer, an oxide layer, and said second wafer;

forming a moving combteeth assembly in said second wafer, said moving

20 combteeth assembly including a paddle and a torsional hinge, said moving combteeth
assembly being separated from said first wafer by said oxide layer; and

removing exposed portions said oxide layer to release said staggered torsional electrostatic combdrive.

- 25 29. The method of claim 28 wherein said forming step includes a first step of etching an external surface oxide layer and a second step of etching said second wafer to form said moving combteeth assembly.
- 30. The method of claim 28 further comprising the step of depositing a reflective30 film on said paddle.